INFORMAL COMMUNICATION PROPOSED AMENDMENT

Serial No. 09/627,559

Examiner Bernard Souw

Art Unit 2881

10 DEC 2002

IN THE SPECIFICATION

Page 4, paragraph starting at line 13:4

The Etendu of a laser plasma source is defined as the product of the illuminated surface of an imaginary unit sphere around the source and the square of the aperture angle Numerical Aperture at which each field point of the imaginary unit source sees the spherical source.

IN THE CLAIMS

(Amended Twice amended) The illumination system of claim 4746, wherein said optical unit comprises a structure having a plurality of sides, wherein each of said plurality of sides corresponds to one of said plurality of primary light sources, and

wherein said second plurality of raster elements is arranged on said plurality of sides.

68. (New) The illumination system of claim 45, wherein said optical unit comprises a structure is

wherein said optical unit comprises a structure having a plurality of sides, wherein each of said plurality of sides corresponds to one of said plurality of primary light sources, and

wherein said second plurality of raster elements is arranged on said plurality of sides.

64. (New) The illumination system of claim 45, wherein said optical unit comprises a plurality of structures,